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APPLICATION NO.	F.	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/778,874	02/08/2001		Mikio Ihama	0042-0437P-SP	6673
2292	7590	12/03/2001			
<del></del>		KOLASCH & B	EXAMINER		
PO BOX 747			WALKE, AMANDA C		
FALLS CHU	JRCH, V	A 22040-0747			
		•		ART UNIT	PAPER NUMBER
				1752	U
				DATE MAILED: 12/03/2001	

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)				
	Office Action Summan	09/778,874	IHAMA, MIKIO				
	Office Action Summary	Examiner	Art Unit				
	The MAII INC DATE of this account.	Amanda C Walke	1752				
Period for	The MAILING DATE of this communication app Reply	ears on the cove <b>r</b> she	et with the correspondence at	uaress			
THE M Extensi after Si If the pe - If NO pe - Failure - Any rep	RTENED STATUTORY PERIOD FOR REPLY AILING DATE OF THIS COMMUNICATION. ons of time may be available under the provisions of 37 CFR 1.13 X (6) MONTHS from the mailing date of this communication. ariod for reply specified above is less than thirty (30) days, a reply eriod for reply is specified above, the maximum statutory period w to reply within the set or extended period for reply will, by statute, ly received by the Office later than three months after the mailing patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, m within the statutory minimum ill apply and will expire SIX (6) cause the application to beco	nay a reply be timely filed of thirty (30) days will be considered time of MONTHS from the mailing date of this of me ABANDONED (35 U.S.C. § 133).	ely. communication.			
1)🛛	Responsive to communication(s) filed on <u>08 F</u>	ebruary 2001 .					
2a)□	This action is <b>FINAL</b> . 2b)⊠ Thi	s action is non-final.					
3)□	Since this application is in condition for allowa closed in accordance with the practice under $t$	nce except for formal Ex parte Quayle, 193	matters, prosecution as to tl 5 C.D. 11, 453 O.G. 213.	he merits is			
Dispositio	n of Claims						
4)⊠ C	claim(s) 1-21 is/are pending in the application						
4a) Of the above claim(s) is/are withdrawn from consideration.							
5)□ C	claim(s) is/are allowed.						
6)⊠ C	claim(s) <u>1-21</u> is/are rejected.						
7)⊠ C	claim(s) <u>9-16</u> is/are objected to.						
8)□ C	claim(s) are subject to restriction and/or	election requirement					
Application	n Papers						
9)[] Th	ne specification is objected to by the Examiner	•					
10) 🔲 Th	ne drawing(s) filed on is/are: a)□ accep	ted or b) objected to	by the Examiner.				
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
	e proposed drawing correction filed on		disapproved by the Examin	ner.			
	If approved, corrected drawings are required in rep						
	e oath or declaration is objected to by the Exa	ıminer.					
	der 35 U.S.C. §§ 119 and 120						
	cknowledgment is made of a claim for foreign	priority under 35 U.S	.C. § 119(a)-(d) or (f).				
•	All b) Some * c) None of:						
	. Certified copies of the priority documents						
	. Certified copies of the priority documents						
	Copies of the certified copies of the priori application from the International Bur e the attached detailed Office action for a list of	eau (PCT Rule 17.2(	a)).	Stage			
	knowledgment is made of a claim for domestic	•		l application).			
_	☐ The translation of the foreign language prov	•	.,,,,,	,			
15) <u></u> Acl	knowledgment is made of a claim for domestic	* *					
Attachment(s)							
2) Notice o	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) tion Disclosure Statement(s) (PTO-1449) Paper No(s) <u>2</u> .		riew Summary (PTO-413) Paper No e of Informal Patent Application (PT :				
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Application/Control Number: 09/778,874

Art Unit: 1752

#### **DETAILED ACTION**

### Claim Objections

1. Claims 9-16 are objected to because of the following informalities: Claims 9-16 recite "no dislocation line", but should read "no dislocation lines". Appropriate correction is required.

# Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Brust et al (6,100,019) in view of Nisikawa et al (6,007,977).

Brust et al disclose a silver halide photographic material comprising high bromide {111} tabular grains having a high chloride epitaxy. The grains are preferably silver iodochlorobromide and contain silver iodide in an amount of less than 10 mole %, and silver chloride in an amount of less than 10 % as well (column 3, line 53 to column 4, line 35). It would have been obvious to one of ordinary skill in the art to prepare the emulsion using any amount within these ranges. Additionally, the inventive grains comprise either 0.75 mol % or 1.2 mol % iodide. The epitxial deposits may constitute only 0.1 % of the total silver, thus the chloride may be added in an amount as low as 0.1 mol %. The grains account for at least 90 %, most preferably greater than 97 % of the total grain projected area, have a thickness of less than 0.2 microns, preferably less than 0.07 microns, an ECD of less than 6 microns, and an aspect ratio of at least 5 (column 5, lines 30-57). The grains may be hexagonal (column 7, lines 34-50). The grains contain high

Application/Control Number: 09/778,874

Art Unit: 1752

deposits, one in each corner of the grain, which implies that the grains formed by the examples are hexagonal grains. The pBr during emulsion preparation is preferably adjusted to be between 3.0 and 3.8, after the temperature has been set between 20 and 60 degrees C, and from looking at the inventive examples the temperature is preferably 40 degrees C (column 6, lines 45-67). The exemplified grains also contain one or more dislocation lines at the epitaxial junctions, demonstrating that the grains may have dislocation lines at the apexes of the grains. The material comprising the emulsion is coated on a support (column 10, lines 15-18).

Although the material does not specifically refer to the COV of the ECD of the grains, since the reference teaches that the emulsion should be monodisperse, that the COV would inherently be very low and would be less than less than the 30% and 20 % claimed given that it is most preferable for greater than 97 % of the emulsion to be comprised of the preferred grains which would have an ECD within the claimed range. The reference fails to disclose specific information on the edge lengths of the hexagonal grains.

Nishikawa et al disclose a silver chloroiodobromide {111} emulsion comprising hexagonal grains containing dislocation lines in the apexes of the grains (column 4, lines 1-46). The reference teaches that it is preferable for hexagonal grains to have a ratio of the longest side to the shortest side of 2 or less (column 3, lines 11-26), and further teaches that a monodisperse emulsion will have a low COV of the ECD (15 5 or less) of the grains.

It would have been obvious to one of ordinary skill in the art to prepare the monodisperse high bromide {111} hexagonal grain emulsion of Brust et al using hexagonal grains having a ratio of the longest side to the shortest side of 2 or less given that it is taught to be preferable by



Application/Control Number: 09/778,874

Art Unit: 1752

Maruyama et al with reasonable expectation of achieving an emulsion having high sensitivity and graininess.

#### Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Reed et al (5,698,387), Jagannathan et al (5,723,278), and Maruyama et al (6,153,370) are cited for their discloses of similar silver halide grains and emulsions.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Amanda C Walke whose telephone number is 703-305-0407. The examiner can normally be reached on M-R 5:30-4.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Janet Baxter can be reached on 703-308-2303. The fax phone numbers for the organization where this application or proceeding is assigned are 703-305-3599 for regular communications and 703-872-9792 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

Amanda C Walke Examiner

Art Unit 1752

JANET BAXTER

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700

ACW November 7, 2001